

## Electronic Acknowledgement Receipt

<b>EFS ID:</b>	1456782
<b>Application Number:</b>	10622001
<b>International Application Number:</b>	
<b>Confirmation Number:</b>	2266
<b>Title of Invention:</b>	Electro-chemical deposition system and method of electroplating on substrates
<b>First Named Inventor/Applicant Name:</b>	Uziel Landau
<b>Customer Number:</b>	44257
<b>Filer:</b>	Steven Harry VerSteeg
<b>Filer Authorized By:</b>	
<b>Attorney Docket Number:</b>	AMAT/2601.R02/CPI/COPPER/
<b>Receipt Date:</b>	22-JAN-2007
<b>Filing Date:</b>	17-JUL-2003
<b>Time Stamp:</b>	19:38:19
<b>Application Type:</b>	Utility

### Payment information:

Submitted with Payment	no
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### File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1	Information Disclosure Statement (IDS) Filed	APPM002601R2_SIDS012207_EF.pdf	228971	no	3

### Warnings:

**Information:**

This is not an USPTO supplied IDS fillable form

**Total Files Size (in bytes):**

228971

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**New Applications Under 35 U.S.C. 111**

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

**National Stage of an International Application under 35 U.S.C. 371**

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.